

Third Edition

# Practical Guide to ICP-MS

A TUTORIAL FOR BEGINNERS



**ROBERT THOMAS**



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# Contents

Foreword .....	xv
Preface.....	xix
Acknowledgment .....	xxv
Author .....	xxvii
<b>Chapter 1</b> An Overview of ICP-MS .....	1
Principles of Operation.....	1
<b>Chapter 2</b> Principles of Ion Formation.....	5
Ion Formation .....	5
Natural Isotopes .....	7
<b>Chapter 3</b> Sample Introduction .....	11
Aerosol Generation.....	11
Droplet Selection .....	13
Nebulizers .....	14
Concentric Design .....	15
Cross-Flow Design .....	16
Microflow Design .....	16
Spray Chambers .....	18
Double-Pass Spray Chamber.....	19
Cyclonic Spray Chamber.....	19
Aerosol Dilution.....	20
<b>Chapter 4</b> Plasma Source .....	23
The Plasma Torch.....	24
Formation of an ICP Discharge.....	26
The Function of the RF Generator .....	27
Ionization of the Sample.....	28
<b>Chapter 5</b> Interface Region .....	31
Capacitive Coupling .....	33
Ion Kinetic Energy .....	34
Benefits of a Well-Designed Interface.....	36
<b>Chapter 6</b> Ion-Focusing System .....	39
Role of the Ion Optics.....	39

Dynamics of Ion Flow .....	41
Commercial Ion Optic Designs .....	43
<b>Chapter 7</b> Mass Analyzers: Quadrupole Technology .....	47
Quadrupole Technology .....	48
Basic Principles of Operation .....	48
Quadrupole Performance Criteria .....	50
Resolution .....	51
Abundance Sensitivity .....	52
Benefit of Good Abundance Sensitivity .....	53
<b>Chapter 8</b> Mass Analyzers: Double-Focusing Magnetic Sector Technology .....	55
Magnetic Sector Mass Spectroscopy: A Historical Perspective .....	55
Use of Magnetic Sector Technology for ICP-MS .....	56
Principles of Operation of Magnetic Sector Technology .....	58
Resolving Power .....	58
Other Benefits of Magnetic Sector Instruments .....	60
Simultaneous Measurement Approach Using One Detector .....	62
Summing Up .....	64
<b>Chapter 9</b> Mass Analyzers: Time-of-Flight Technology .....	65
Basic Principles of Time-of-Flight (TOF) Technology .....	65
Commercial Designs .....	66
Differences between Orthogonal and On-Axis TOF .....	69
Benefits of TOF Technology for ICP-MS .....	70
Rapid Transient Peak Analysis .....	70
Improved Precision .....	71
Rapid Data Acquisition .....	71
<b>Chapter 10</b> Mass Analyzers: Collision/Reaction Cell and Interface Technology .....	73
Basic Principles of Collision/Reaction Cells .....	74
Different Collision/Reaction Cell Approaches .....	75
Collisional Mechanisms Using Nonreactive Gases and KED .....	76
Reaction Mechanisms with Highly Reactive Gases and Discrimination by Selective Bandpass Mass Filtering .....	80
Dynamic Reaction Cell .....	80
Low Mass Cut-Off Collision/Reaction Cell .....	84
“Triple Quadrupole” Collision/Reaction Cell .....	86
MS Mode .....	87
MS/MS Mode .....	87
On-Mass MS/MS Mode .....	87

Mass-Shift MS/MS Mode .....	89
The Collision/Reaction Interface .....	90
Using Reaction Mechanisms in a Collision Cell.....	92
The “Universal” Cell .....	96
Detection Limit Comparison.....	96
Summing Up .....	97
<b>Chapter 11</b> Ion Detectors .....	99
Channel Electron Multiplier.....	99
Faraday Cup .....	100
Discrete Dynode Electron Multiplier .....	101
Extending the Dynamic Range .....	102
Filtering the Ion Beam.....	102
Using Two Detectors .....	102
Using Two Scans with One Detector.....	103
Using One Scan with One Detector .....	103
Extending the Dynamic Range Using Pulse-Only Mode .....	106
Simultaneous Array Detectors .....	106
<b>Chapter 12</b> Peak Measurement Protocol.....	109
Measurement Variables .....	109
Measurement Protocol.....	110
Optimization of Measurement Protocol.....	114
Multielement Data Quality Objectives.....	115
Data Quality Objectives for Single-Particle ICP-MS Studies .....	121
<b>Chapter 13</b> Methods of Quantitation .....	123
Quantitative Analysis .....	123
External Standardization.....	124
Standard Additions .....	125
Addition Calibration.....	126
Semiquantitative Analysis.....	126
Isotope Dilution.....	128
Isotope Ratios .....	131
Internal Standardization.....	131
<b>Chapter 14</b> Review of Interferences.....	133
Spectral Interferences.....	133
Oxides, Hydroxides, Hydrides, and Doubly Charged Species ....	135
Isobaric Interferences .....	136
Ways to Compensate for Spectral Interferences.....	136
Mathematical Correction Equations.....	136

	Cool/Cold Plasma Technology .....	138
	Collision/Reaction Cells .....	139
	High-Resolution Mass Analyzers .....	140
	Matrix Interferences .....	140
	Compensation Using Internal Standardization .....	141
	Space-Charge-Induced Matrix Interferences .....	142
<b>Chapter 15</b>	<b>Sample Preparation .....</b>	<b>145</b>
	Collecting the Sample .....	145
	Preparing the Sample .....	146
	Grinding the Sample .....	146
	Sample Dissolution Methods .....	147
	Choice of Reagents and Standards .....	149
	Vessels, Containers, and Sample Preparation Equipment .....	150
	The Environment .....	153
	The Analyst .....	154
	Instrument and Methodology .....	155
<b>Chapter 16</b>	<b>Routine Maintenance .....</b>	<b>159</b>
	Sample Introduction System .....	160
	Peristaltic Pump Tubing .....	160
	Nebulizers .....	161
	Spray Chamber .....	163
	Plasma Torch .....	164
	Interface Region .....	165
	Ion Optics .....	166
	Roughing Pumps .....	167
	Air Filters .....	168
	Other Components to Be Periodically Checked .....	168
	The Detector .....	168
	Turbomolecular Pumps .....	169
	Mass Analyzer and Collision/Reaction Cell .....	169
	Summing Up .....	170
<b>Chapter 17</b>	<b>Alternative Sample Introduction Techniques .....</b>	<b>171</b>
	Laser Ablation .....	172
	Commercial Systems for ICP-MS .....	173
	Excimer Lasers .....	173
	Benefits of Laser Ablation for ICP-MS .....	174
	Optimum Laser Design Based on Application Requirements ....	175
	193-nm ArF Laser Technology .....	178
	Flow Injection Analysis .....	179
	Electrothermal Vaporization .....	182
	Chilled Spray Chambers and Desolvation Devices .....	186

Water-Cooled and Peltier-Cooled Spray Chambers .....	187
Ultrasonic Nebulizers .....	188
Specialized Microflow Nebulizers with Desolvation Techniques .....	190
Direct Injection Nebulizers (DIN) .....	192
Enhanced Productivity Sampling Systems .....	193
Faster Analysis Times .....	194
Automated Inline Autodilution and Autocalibration .....	195
Automated Inline Chemistry Methods .....	197
<b>Chapter 18</b> Coupling ICP-MS with Chromatographic Techniques for Trace Element Speciation .....	201
HPLC Coupled with ICP-MS .....	204
Chromatographic Separation Requirements .....	205
Ion Exchange Chromatography (IEC) .....	205
Reversed-Phase Ion Pair Chromatography (RP-IPC) .....	206
Column Material .....	207
Isocratic or Gradient Elution .....	207
Sample Introduction Requirements .....	208
Optimization of ICP-MS Parameters .....	210
Compatibility with Organic Solvents .....	211
Collision/Reaction Cell or Interface Capability .....	211
Optimization of Peak Measurement Protocol .....	212
Full Software Control and Integration .....	215
Summing Up .....	215
<b>Chapter 19</b> Common ICP-MS Applications .....	217
Environmental .....	218
Biomedical .....	223
Sample Preparation .....	224
Interference Corrections .....	224
Calibration .....	225
Stability .....	226
Geochemical .....	227
Determination of Rare Earth Elements .....	228
Analysis of Digested Rock Samples Using Flow Injection (FI) ..	229
Geochemical Prospecting .....	231
Isotope Ratio Studies .....	232
Laser Ablation .....	234
Semiconductor .....	235
Nuclear .....	239
Applications Related to the Production of Nuclear Materials ..	242
Applications in the Characterization of High-Level Nuclear Waste .....	242



Applications Involving the Monitoring of the Nuclear Industry's Impact on the Environment .....	243
Applications Involving Human Health Studies .....	244
Other Applications .....	244
Metallurgical Applications .....	245
Petrochemical and Organic-Based Samples .....	247
Food and Agriculture .....	249
Pharmaceutical .....	253
Summing Up .....	255
<b>Chapter 20</b> Emerging ICP-MS Application Areas.....	257
Analysis of Power Plant Flue Gas Desulfurization Wastewaters (FGDW) .....	257
Draft of U.S. EPA ICP-MS Standard Operating Procedure for FGDW Samples.....	259
Method of Sample Preparation.....	260
Instrument Parameters.....	260
Proposed U.S. EPA FGDW Methodology .....	260
Multielement Analysis of Seawater Using Automated Inline Chemistry Procedures .....	262
Analytical Methodology .....	264
Sample Preparation.....	264
ICP-MS Instrumental Parameters .....	264
seaFAST 3 Modes of Operation.....	264
Results .....	266
Characterization of Nanoparticles by ICP-MS .....	268
Engineered Nanomaterials (ENMs) .....	268
Potential for Environmental Impact .....	269
Analytical Methodologies .....	270
Single Particle ICP-MS Studies.....	271
Optimized Measurement Protocol .....	273
Field Flow Fractionation (FFF) Coupled with ICP-MS .....	274
FFF Coupled with ICP-MS .....	276
Particle Size Reference Standards.....	276
Calibration Strategies .....	277
Recovery .....	278
<b>Chapter 21</b> Comparing ICP-MS with Other Atomic Spectroscopic Techniques .....	281
Flame Atomic Absorption.....	283
Electrothermal Atomization (ETA).....	283
Radial-View ICP Optical Emission.....	283
Axial-View ICP Optical Emission .....	283
Inductively Coupled Plasma Mass Spectrometry.....	284

Define the Objective .....	284
Establish Performance Criteria .....	284
Define the Application Task .....	284
Application.....	285
Installation .....	285
User .....	285
Financial .....	285
Comparison of Techniques .....	285
Detection Limits .....	286
Analytical Working Range .....	288
Sample Throughput .....	288
Interferences .....	290
Usability.....	290
Cost of Ownership.....	291
Summing Up .....	298
<b>Chapter 22</b> How to Select an ICP Mass Spectrometer: Some Important Analytical Considerations .....	301
Evaluation Objectives.....	301
Analytical Performance.....	302
Detection Capability .....	303
Precision .....	307
Isotope Ratio Precision .....	309
Accuracy .....	311
Dynamic Range .....	312
Interference Reduction.....	314
Reduction of Matrix-Induced Interferences .....	322
Sample Throughput .....	324
Transient Signal Capability .....	326
Single-Particle ICP-MS Transient Signals .....	327
Usability Aspects.....	329
Ease of Use .....	329
Routine Maintenance.....	330
Compatibility with Alternative Sampling Accessories .....	332
Installation of Instrument .....	332
Technical Support.....	332
Training .....	333
Reliability Issues .....	333
Service Support.....	334
Financial Considerations.....	335
Evaluation Process: A Summary.....	336
<b>Chapter 23</b> Final Thoughts .....	337

<b>Appendix: Useful Contact Information</b> .....	341
<b>Glossary of ICP-MS Terms</b> .....	351
<b>References</b> .....	393
<b>Index</b> .....	411